<u>Characterization of the Surface Properties</u> <u>of Nanoparticles Using Moisture</u> <u>Adsorption Dynamic Profiling</u>

Hao Wang

Chemical and Environmental Engineering University of Arizona

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ESH Testing and Evaluation of New Chemicals



Handy, R.D., Shaw, B.J., 2007. Toxic effects of nanoparticles and nanomaterials: Implications for public health, risk assessment and the public perception of nanotechnology. Health Risk Society 9, 125-144.

FTIR Application on Quantitative

<u>Measurements</u>



Bordiga, S et al., 2005. FTIR adsorption studies of H₂O and CH₃OH in the isostructural H-SSZ-13 and H-SAPO-34: formation of H-bonded adducts and protonated clusters. J. Phys. Chem. B 109, 7724-7732.

Objectives and Method Approach

- <u>Objective</u>: Characterization of the surface sites on nanoparticles that contribute to concentration, retention, and enhanced transport of toxic chemicals.
- <u>Method approach</u>: Surface hydroxylation (adsorption and desorption of contaminants).
- <u>Materials</u>: SiO₂, HfO₂, and CeO₂.
- <u>Parameters</u>: Oxide type, particle size, temperature.
- <u>Results</u>: Capacity and energetics of capture and retention of contaminants on active sites.

NPs	Supplier	APS* (reported by supplier) (nm)
CeO ₂	Sigma-Aldrich	20
SiO ₂	Sigma-Aldrich	10-20
HfO ₂	Sematech	20
HfO ₂	American Elements	100



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Voltage Input	Temperature
0 V	25°C
30 V	55°C
45 V	80°C

Schematic Diagram of the NP Sample Holder



Mechanism of Multilayer Model

Adsorption rate coefficient

 $k_a = k_{a_0} exp(\frac{-E_a}{RT})$

Adsorption activation energy



1: Chemisorption



$$k_d = k_{d_0} exp(\frac{-E_d}{RT})$$

Desorption activation energy



2: Physisorption



Process Simulation for Data Analysis

Adsorbent concentration in the gas phase:

$$\frac{\partial C_g}{\partial t} = \underline{D_e \frac{\partial^2 C_g}{\partial x^2}} + (1 - \varepsilon) \frac{3}{r} \underline{[k_d C_s - k_a C_g (S_0 - C_s)]}$$

Diffusion term Adsorption and desorption term

Adsorbent concentration on the surface:

$$\frac{\partial C_s}{\partial t} = k_a C_g (S_0 - C_s) - k_d C_s$$

- $C_g C_s$ concentration in the gas phase, gmol·m⁻³
- concentration on the surface, $gmol \cdot m^{-2}$
- adsorption rate coefficient, m³·gmol⁻¹·s⁻¹
- desorption rate coefficient, s⁻¹ k_d

- maximum capacity of the surface, gmol·m⁻² S₀
- packing porosity 3
- radius of nanoparticle, m r
- effective diffusivity, m²·s⁻¹ D



Substrate





Activation Energy of Surface Processes





- The surface retention characteristics depend on the material as well as on the particle size.
- The affinity of nanoparticles for adsorption and retention decreases in the order: $CeO_2 > HfO_2 > SiO_2$. The surface available sites under certain challenge concentrations decreases in the order: $SiO_2 > HfO_2 > CeO_2$.
- Nanoparticles with smaller size will have larger density of surface sites and larger surface retention capacity for most cases. They also have higher affinity for retention of contaminants.

Parametric study of Species Effect

Sample	Maximum capacity	Saturated surface	Fractional coverage		
(20nm)	$S_0 (gmol \cdot m^{-2})$	concentration	θ (%)		
		C _{s, 0} (gmol·m ⁻²)			
SiO ₂	7.1×10 ⁻⁶ ▲	2.8×10 ⁻⁶	39		
HfO ₂	1.5×10 ⁻⁶	1.1×10 ⁻⁶	73		
CeO ₂	5.5×10-7	5.4×10-7	98 🗸		

Sample	k _{a, 0}	k _{d, 0}	E _{a, 1}	E _{a, 2}	E _{d, 1}	E _{d, 2}
(20nm)	$(m^3 \cdot gmol^{-1} \cdot s^{-1})$	(s -1)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)
SiO ₂	0.028	0.003	4.5	4.0	6.0	3.0
HfO ₂	0.200	0.010	0.8	0.3	12.0	1.0
CeO ₂	0.800	0.003	1.2	1.0	9.0	2.0

Parametric study of Size Effect

Sample	Maximum capacity	Saturated surface	Fractional coverage	
	S₀ (gmol·m ⁻²)	concentration	θ (%)	
		$C_{s, 0}$ (gmol·m ⁻²)		
HfO ₂ (20nm)	1.5×10 ⁻⁶ ↑	1.1×10 ⁻⁶	73	
HfO ₂ (100nm)	8.7×10 ⁻⁷	7.3×10 ⁻⁷	84 🗸	

Sample	k _{a, 0}	k _{d, 0}	E _{a, 1}	E _{a, 2}	E _{d, 1}	E _{d, 2}
	$(m^3 \cdot gmol^{-1} \cdot s^{-1})$	(s ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)
HfO ₂ (20nm)	0.20	0.010	0.8	0.3	12.0	1.0
HfO ₂ (100nm)	1.29	0.035	0.6	0.4	6.0	1.2

Separate Domain Process Simulation

Nanoparticle

Sample holder

r=()

 $r=r_0$

x=L/2

x=0

Nanoparticle Domain

Adsorbent concentration in the gas phase:

$$\frac{\partial C_{g_{in}}}{\partial t} = D_{e_{in}} \frac{1}{r^2} \frac{\partial}{\partial r} (r^2 \frac{\partial C_{g_{in}}}{\partial r}) + [k_d C_{s_{in}} - k_a C_{g_{in}} (S_0 - C_{s_{in}})] \frac{A}{V}$$

Adsorbent concentration on the surface:

$$\frac{\partial C_{s_{in}}}{\partial t} = k_a C_{g_{in}} (S_0 - C_{s_{in}}) - k_d C_{s_{in}}$$

Sample Holder Domain

Adsorbent concentration in the gas phase:

$$\frac{\partial C_{g_{out}}}{\partial t} = D_{e_{out}} \frac{\partial^2 C_{g_{out}}}{\partial x^2} - D_{e_{in}} \frac{C_{g_{in}}}{r}|_{r=r_0} 4\pi r_0^2 N_v$$

Numerical Method



Comparison of Adsorption Profiles of NPs



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Effect of Temperature on Surface Retention

HfO₂, 20nm





Adsorption Activation Energy of Surface Processes



Desorption Activation Energy of Surface Processes





Parametric study of Temperature Effect

Sample	Maximum capacity	Saturated surface	Fractional coverage
(20nm)	$S_0 (gmol \cdot m^{-2})$	concentration	θ (%)
		$C_{s, 0} (gmol \cdot m^{-2})$	
HfO ₂ , 25°C	1.5×10 ⁻⁶	1.1×10-6	↑ 73 ↑
HfO ₂ , 55°C	1.5×10 ⁻⁶	7.4×10 ⁻⁷	49
HfO ₂ , 80°C	1.5×10 ⁻⁶	4.0 ×10 ⁻⁷	27 I

Sample	k _{a, 0}	k _{d, 0}	E _{a, 1}	E _{a, 2}	E _{d, 1}	E _{d, 2}
(20nm)	(m ³ ·gmol ⁻¹ ·s ⁻¹)	(s ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol ⁻¹)	(kJ·gmol·1)
HfO ₂ , 25°C	0.03	0.0025	5.0	/ 0.5 \	/ 15.0 \	/ 2.4 \
HfO ₂ , 55°C	0.03	0.0025	5.0	2.8	21.5	2.0 1
HfO₂, 80°C	0.03	0.0025	5.0	4.8	21.0	

Summary and Conclusions I



NPs.



The surface retention characteristics depend on the material as well as on the particle size.



The affinity of nanoparticles for adsorption and retention decreases in the order: $CeO_2 > HfO_2 > SiO_2$. The surface available sites under certain challenge concentrations decreases in the order: $SiO_2 > HfO_2 > CeO_2$.



Nanoparticles with smaller size will have larger density of surface sites and larger surface retention capacity for most cases. They also have higher affinity for retention of contaminants.

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Summary and Conclusions II



Purge under the higher temperature will reach the same baseline more faster.



The affinity of HfO_2 under different temperatures for moisture retention decreases in the order: $25^{\circ}C > 80^{\circ}C > 55^{\circ}C$. The saturated surface concentration under certain challenge concentrations decreases in the order: $25^{\circ}C > 55^{\circ}C > 80^{\circ}C$.



The adsorption and desorption activation energy of moisture on HfO_2 decreases in the order: $80^{\circ}C > 55^{\circ}C > 25^{\circ}C$.

4.0335	
4.033	ε _{in} =0.20
ğ 4.0325	
4.032	-
≤ 4.0315	
S 4.031	-
4.0305	
4.03	- · · · · · · ·

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Higher NP porosity will increase the diffusivity inside of the NP, and it will have higher desorption rate.

Future Work

Keep on studying the surface properties of different NPs under various temperatures

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Upgrade the experimental setup to increase the energy of the IR light to get more intensity of absorbance

Upgrade the numerical model for porous NPs and increase the efficiency

